## S PATENT AND TRADEMARK OFFICE

In re Application of:

PARK et al.

Application No.: 09/839,594

Art Unit:

Unassigned

Filed:

April 23, 2001

Examiner:

Unassigned

For:

LOW DIELECTRIC **COMPOSITE WITH** NANO MAGNETIC

PARTICLES,

**MANUFACTURING** METHOD THEREOF,

AND

**SEMICONDUCTOR** 

**DEVICE AND** 

OPTICAL DEVICE USING THE SAME

## **CLAIMS PENDING AFTER PRELIMINARY AMENDMENT**

1. A composite comprising:

a dielectric matrix; and

nano magnetic particles contained in the matrix.

- 2. The composite according to claim 1, wherein the nano magnetic particles are non-spherical.
- 3. The composite according to claim 2, including spherical nano magnetic particles in addition to the non-spherical nano magnetic particles.
- 4. The composite according to claim 1. wherein the nano magnetic particles are spherical.

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- 5. The composite according to claim 1. wherein the matrix is selected from the group consisting of silica, alumina, and hydrosilsesquioxane.
- 6. The composite according to claim 1, wherein the matrix is selected from the group consisting of polyimide, PMMA, and methyl silsesquioxane.
- 7. The composite according to claim 1, wherein the nano magnetic particles are superparamagnetic.
- 8. The composite according to claim 7, including diamagnetic nano magnetic particles in addition to the superparamagnetic nano particles.
- 9. The composite according to claim 8, wherein the diamagnetic nano particles include indium (In).
- 10. The composite according to claim 1, wherein the nano magnetic particles are diamagnetic.
- 11. The composite according to claim 1, wherein the nano magnetic particles are selected from the group consisting of (y-Fe<sub>2</sub>O<sub>3</sub>), chromium oxide (CrO<sub>2</sub>), europium oxide (EuO), NiZn-ferrite, MnZn-ferrite, and ytrium-iron garnet.
- 12. The composite according to claim 2. wherein the nano magnetic particles include indium.

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13. A semiconductor device comprising:

a semiconductor substrate: and

cupae, for an insulator made of a composite having a dielectric matrix, and nano magnetic particles contained in the matrix.

- 14. The semiconductor device according to claim 13, wherein the nano magnetic particles are non-spherical.
- 15. The semiconductor device according to claim 13, wherein the nano magnetic particles are spherical.
- 16. The semiconductor device according to claim 13, wherein the nano magnetic particles are superparamagnetic.
- 17. The semiconductor device according to claim 15, wherein diamagnetic nano magnetic particles are added to the superparamagnetic nano particles.
  - 18. An optical device comprising:
  - a transparent dielectric matrix; and
  - a composite having nano magnetic particles contained in the matrix.
- 19. The optical device according to claim 18, wherein the nano magnetic particles are non-spherical.
- 20. The optical device according to claim 18, wherein the nano magnetic particles are spherical.
  - 21. A method for manufacturing a composite comprising: forming nano magnetic particles; and distributing the nano magnetic particles in a dielectric matrix.

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22. The method according to claim 21, wherein forming nano magnetic particles includes mixing a cation surfactant with an anion surfactant of a metal salt to form a mixture and subjecting the mixture to chemical sedimentation to form non-spherical nano magnetic particles.